Erratum: First-principles Study of Si-embedded Ni(100) Surfaces

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The affiliation of the first author (T. F.) was wrong in the original article [1]. The correct affiliation is as follows:

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The mistake occurs in the course of the editorial process.

References

[1] T. Fukuda and I. Kishida, *e-J. Surf. Sci. Nanotechnol.* **19**, 112 (2021).

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